

Enhanced MgF₂ and LiF Over-coated Al Mirrors for FUV Space Astronomy

By

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Outlines



- Motivation: The need for better performing coatings in the Far-Ultraviolet (FUV)
- Enhanced UV coating development for the Thermospheric Temperature Imager (TTI)
- More recent research efforts:
 - Preparation of 2-meter coating chambers
 - Study of other low-absorptions dielectric coatings for FUV applications
- Conclusions
- Acknowledgements

Enhanced FUV Coating Applications

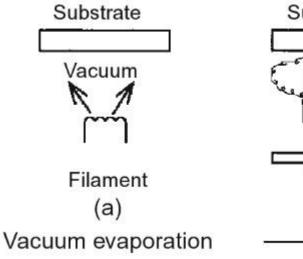


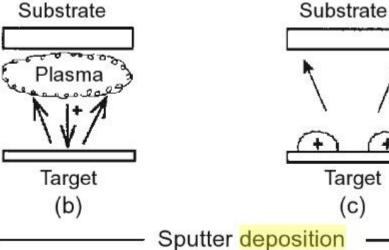
- Distant and faint objects are typically searched for in cosmic origin studies:
 - Origin of large scale structure
 - The formation, evolution, and age of galaxies
 - The origin of stellar and planetary systems
- Astronomical observations in the Far Ultraviolet (FUV) spectral region are some of the more challenging
- Very limited option of reflecting coatings to use at FUV wavelengths:
 - Modest reflectivity offered by those coatings
 - Al+MgF₂ [typically 82% at Lyman-alpha, 1216 Å) that are used on reflecting surfaces of FUV instrumentation
- Improved reflective coatings for optics at FUV could yield dramatically more sensitive instruments.
- Permit more instrument design freedom

Optical Coating Deposition Processes



Plasma





PVD

- Material is heated until it reaches vapor form
- Material is deposited on the substrate where it condenses
- Typical deposition rates are 10-100 Å/Sec.

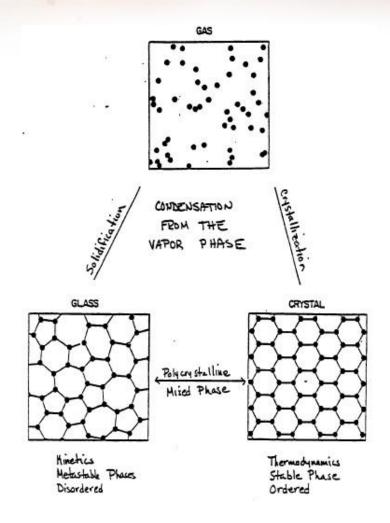
Sputtering

(c)

- Non-thermal evaporation process
- Atoms from a target are ejected by momentum transfer from energetic atom-size particles
- Particles are energized by an ion gun
- Deposition rate are much lower than PVD 1-5 Å/Sec.

Solidification vs. Crystallization



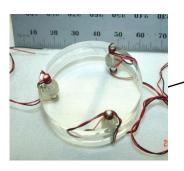


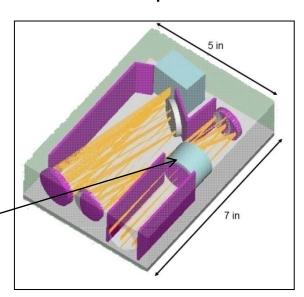
TTI Mission Concept





- Imager to provide global-scale remote measurements of thermospheric temperature profile of atomic oxygen at an altitude of 200-400 KM
- Wavelength range: 135.4 to 135.6 nm (0.0004 nm resolution)
- Fabry-perot Etalon cavity:





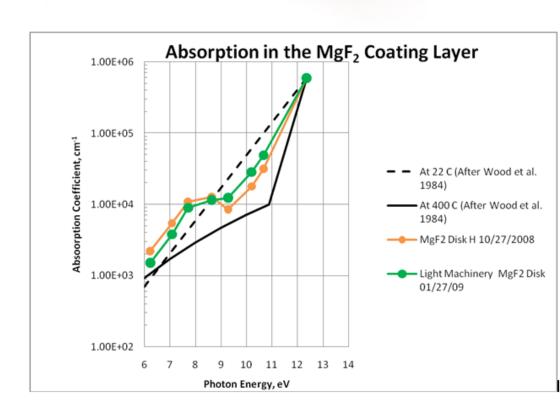
- GSFC effort to develop Al+MgF2 coatings to meet requirements:
 - · High reflectance & low absorption

High-Temperature Deposition Al+MgF2



3-step coating process:

- ✓ Al coat the substrate at room temperature to the planned layer thickness
- ✓ As soon as possible after the AI deposition, overcoat the AI layer and substrate at room temperature with a thin 4-5 nm layer of MgF₂ in order to protect the AI from oxidation and contamination.
- ✓ Heat the substrate to maximum temperature and overcoat the thin MgF2 , Al, and substrate with the planned thickness of MgF2.



TTI Etalon Plate Performance



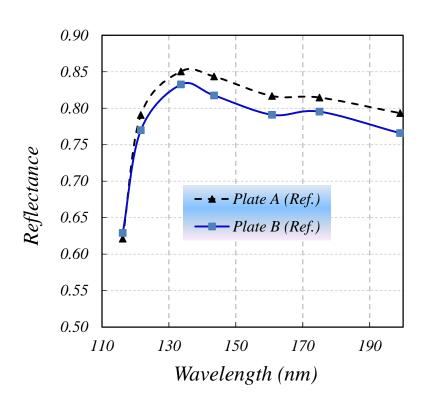
Reflectance

0.10 0.09 0.08 0.07 Transmittance 0.07 0.08 0.09 – Plate A (Trans.)

0.01

0.00

110



TTI Etalon plate 6a (Thicknesses: Al 277 A; MgF2 300A)

TTI Etalon plate 6b (Thicknesses: Al 278 A; MgF2 310A)

130

150

Wavelength (nm)

Plate B (Trans.)

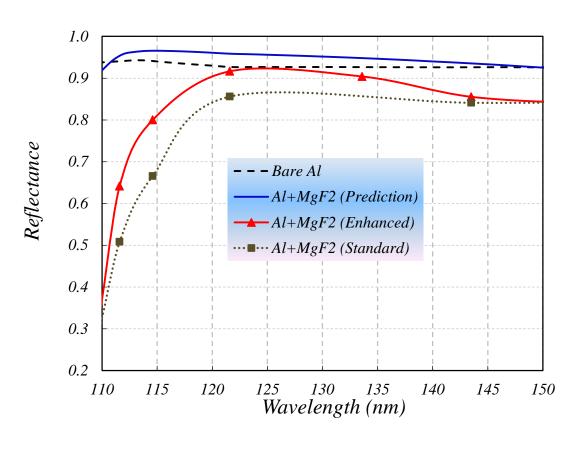
170

190

Transmittance

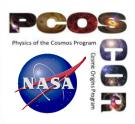
Evaporated Al+MgF2 Mirror Performance

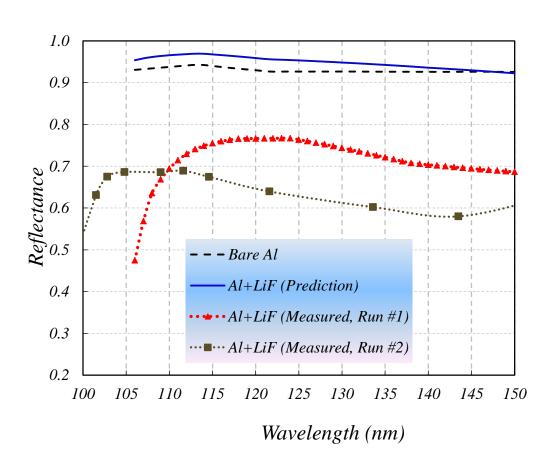




- Predicted vs. measured reflectance of bare Al and Al+MgF₂ reflectance (Al: 50.0 nm; MgF2: 25.0nm)
- Enhanced performance is obtained by heating (~220 ° C) substrate during MgF2 deposition
- Reflectance is > 80% even at 115.0 nm

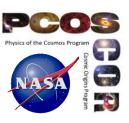
Evaporated Al+LiF Mirror Performance





- Predicted vs. measured reflectance of bare Al and Al+LiF reflectance
- Enhanced performance is obtained by heating substrate during LiF deposition.

Recent Results 1-meter Chamber



Run AMC1207

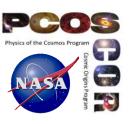
| | Ref AMCT0902A slide AMC1207A center of 14" diam | | optic slide AMC1207B 8" from center of optic | | |
|----------------|---|--------------|---|--|--|
| Wavelength (A) | | | | | |
| *1216 | *0.830850419 | *0.863613442 | *0.840455289 | | |
| 1162 | 0.62643581 | 0.655861189 | 0.741373332 | | |
| 1216 | 0.823922691 | 0.863135491 | 0.855357016 | | |
| 1608 | 0.845185596 | 0.881918126 | 0.818922628 | | |

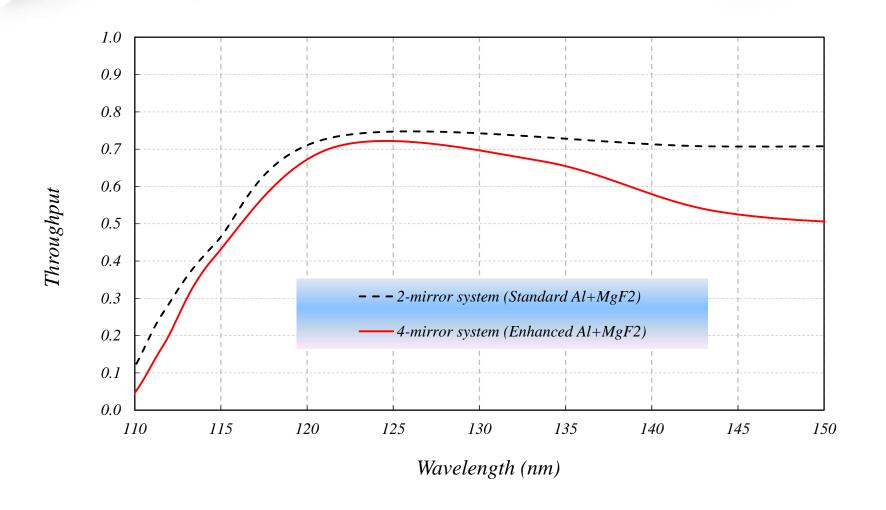
Run AMC1208

| | Ref AMCT0902A | AMC1208 3" from center of chambe | | |
|----------------|---------------|----------------------------------|--|--|
| Wavelength (A) | | | | |
| *1216 | *0.811149486 | *0.890760365 | | |
| 1162 | 0.623358305 | 0.809512748 | | |
| 1216 | 0.814559749 | 0.896448174 | | |
| 1608 | 0.815977285 | 0.843056068 | | |

note: * indicates initial measurement

Throughput Performance for 2- and 4-meter Systems





GSFC 2-meter Coating Facility



- ➤ Design and fabrication of internal heat shields for 2-meter Chamber.
- ➤ Optimized coating parameter for high FUV reflectance of a distribution of slides in center and out to a ~0.5 meter radius.



FIREBALL primary mirror loading



Mirror mounted in 2-meter chamber prior to coating

Missions supported: Astronomical Observatory (OAO) & Ultraviolet Explorer (IUE)

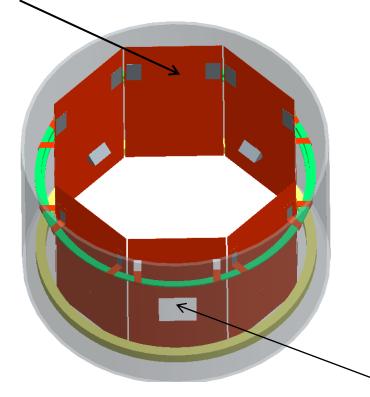
FUSE, HST (COSTAR, GHRS & COS)

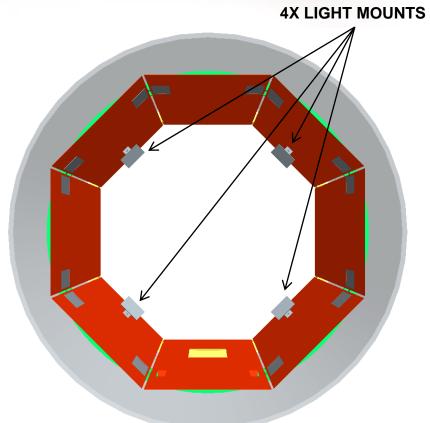
2-meter Chamber Heat Panel Concept

Physics of the Cosmos Program
Cosmic Organs
Program
Program
Cosmic Organs
Program
Prog

- These wall panels were made out of stainless steel and were designed to easily interface with the existing internal configuration of the chamber.
- We are still in the design phase of the top shields for future installation in the chamber dome.
- We recently test fit the wall panels in the co.

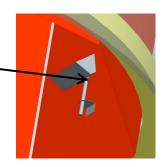
8 PANELS



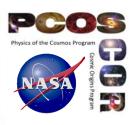


ADJUSTABLE LIGHT MOUNT

SINGLE VIEWPORT 10" X 10" SQUARE



Halogen-Quartz Lamp Heater Equipment







Quartz Lamp Heater Assembly

Power Supply System

FUV Reflecting Dielectric Coatings



- Choose a high-index (H) and low-index (L) pair combination
- Form a pair of (H,L) layers with thicknesses equal to a Quarter-Wave Optical thickness at the design wavelength.
- Repeat the stack above until desired reflectance is achieved.

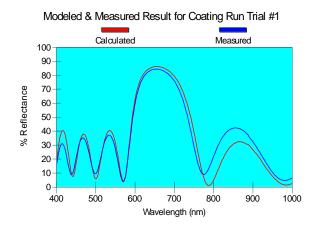


Note: The larger the difference between (n_H-n_L) the better contrast and fewer layers needed to achieve a given R

Options for coating materials:

L: $MgF_2(n\sim1.38)$

H: ?



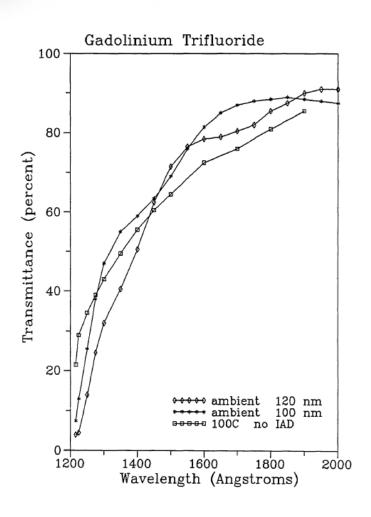
Evaporation Details for Lanthanide Trifluorides

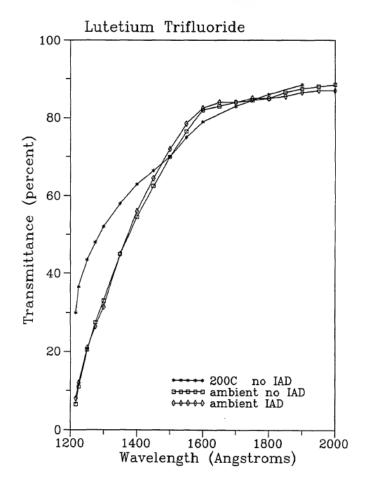
| LnF ₃ | VENDOR & FORM | PURITY | PRICE per gram | BOAT (5 mil canoe) | RATE Å/sec | MELT COMMENTS |
|------------------|---|--------------------------------|----------------------|---------------------------------|---------------|--|
| PrF ₃ | Cerac 3-6mm fused 1/8-1/4" pieces | 99.9 vac. dep. grade | \$1.60 | W (no Mo,Ta) | 6 | bright green smooth melt large, shiny grains |
| SmF ₃ | • | • | \$ 1.62 | Мо | 6 | pale yellow uneven melt small, dull grains |
| EuF ₃ | • | | \$16.00 | Pt sheet 2 mil (no Mo,Ta) | 4 | light brown smooth melt large, shiny grains |
| GdF ₃ | | | \$1.70 | Мо | 6 | white, grey uneven melt small, shiny grains |
| TbF ₃ | | | \$ 7.50 | Ta | 4 | white, grey smooth melt small, shiny grains |
| DyF ₃ | | | \$1.60 | Та | 6 | dark grey smooth melt small, shiny grains |
| HoF ₃ | | • | \$2.30 | Та | 6 | pink smooth melt large, shiny grains |
| ErF ₃ | | " | \$1.90 | Та | 6 | pink smooth melt large, dull grains |
| TmF ₃ | | • | \$ 18.30 | Мо | 6 | white, grey smooth melt large, dull grains |
| YbF ₃ | | • | \$2.40 | Mo (no Ta) | 3 | tan smooth melt large, dull grains |
| LuF, | Aesar crystalline lump | 99.99 elec.grade low oxy | \$37.00 \$45.00 | Mo Mo | 6 6 | white whiter smooth melt large, dull grains |

Ref.: Linda Jeanne Lingg, Ph.D. Thesis University of Arizona (1990).

Two FUV Candidate Materials: GdF₃ & LuF₃







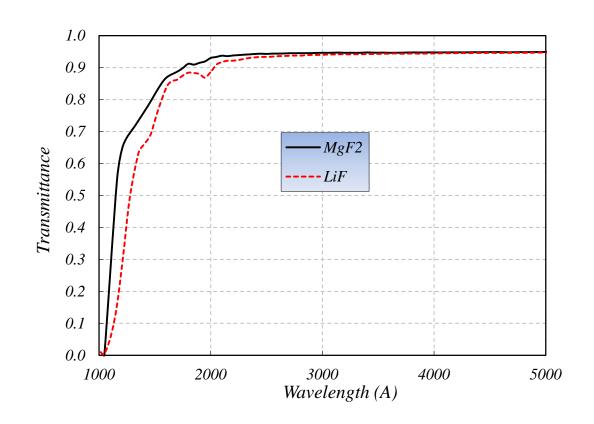
Substrates Characterization



Optical Transmission

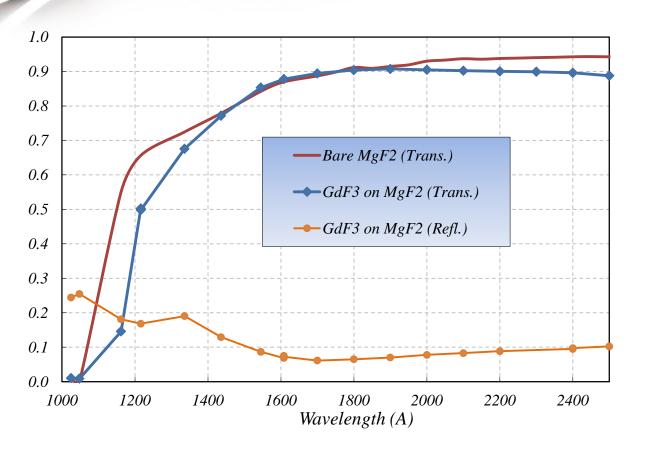


MgF₂ & LiF substrates have been procured



GdF3 Film on MgF2 Substrate





- 430 A GdF3 film on MgF2 substrate
- Measured T & R will enable characterization of n & k

Ion Beam Sputtering Coating Chamber



- Upgrade chamber with a two-gas flow controller system.
- Received shipment of Krypton gas cylinder to be used in the ion-beam sputtering deposition of MgF2 and LiF coatings.
- Making preparation to start making test coating runs to "break-in" MgF2 targets.
- Placed order of new magnets to refurbish ion gun in order to increase deposition rate.



Conclusion



- ➤ Reported gains in FUV reflectivity of Al+MgF₂ and Al+LiF mirrors by employing a 3-step process during PVD coating deposition of these materials.
- ➤ Preparations under way to transfer process to a large 2-meter chamber for allowing coating up to 1 meter diameter optics.
- ➤ Characterization of lanthanide trifluoride material candidates to determine their FUV transparency for development of dielectric coatings.
- ➤ Advantages of having better performing coatings will add more flexibility to a system design that is certain to improve overall performance.
- ➤ Increasing system throughput is a very cost effective way to achieve more science and often is less costly than simply using a larger primary mirror.



Acknowledgements

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